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IEEE Open Journal of Nanotechnology (OJ-NANO) Special Issue on “Emerging Plasma Nanotechnologies”

The high level of attention and interest to nanoscience and nanotechnology to a large extent is linked to the continuing growth of information society. The development of nanoscience and nanotechnology are carried out by interdisciplinary cooperation among academic and industrial researchers. Plasma technology is the key driver to such development. *IEEE Open Journal of Nanotechnology (OJ-NANO)* will publish collected papers in **Special Issue on "Emerging Plasma Nanotechnologies"**. This special issue will shed light on recent progresses on nanoscience and nanotechnology based on low pressure plasma, atmospheric plasma, and plasma simulation, whereas it will also suggest directions for future research.

Manuscripts for *OJ-NANO* must be prepared using the “IEEE manuscript template” and “Information for Authors” at <https://oj-nano.ieeenano.org/submitting-an-article/>; and be submitted on-line via the IEEE Manuscript Central found at <https://mc.manuscriptcentral.com/oj-nano>. On submission to *OJ-NANO*, authors should *select* the “**Special Issue: Plasma Nanotechnologies**” as a manuscript type instead of “Regular Paper.” Manuscripts must focus on nanotechnology as reflected by technical contents and references.

Deadlines:

Manuscript Submission	January 31, 2022
First Decision to Authors	March 31, 2022
Revision Due (if necessary)	April 30, 2022
Final Notification (Acceptance/Rejection)	May 15, 2022
Final Manuscript Due	June 15, 2022
Special issue/section publication	August 31, 2022

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